

Silicon-Scintillator detectors as a novel concept for medical imaging and dosimetry

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Motivation

The concept of Silicon-Scintillator detectors (SiS) combines advantages



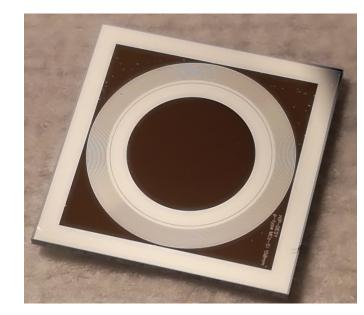
- of two highly developed technologies. It is called to substitute the conventional direct converting detectors (such as CdTe/CdZnTe) in multispectral imaging and dosimetry applications
- Sensors, based on direct converting semiconductor materials, have a merit of high sensitivity to ionizing radiation and provide substantial dose reduction on the patients
- However, expansion of direct converting detectors to the market of medical imaging devices faces significant difficulties due to the limited availability of high-quality sensors

Concept

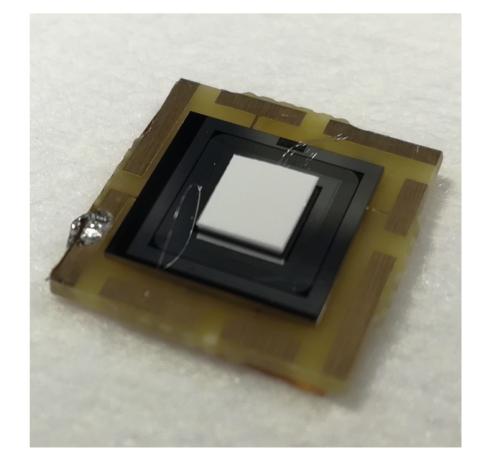
- Main disadvantage of Si detectors is its low effective atomic number (Z_{eff}) for the typical photon energy range of interest in most medical imaging applications (20-200 keV)
- □ On the other hand, most of the inorganic scintillation materials have a high Z_{eff} and, subsequently, sufficient absorption efficiency for the X-ray photons of stated energy range
- **The core of the concept involves enhancement of Si detector by**
- Tests have been performed under several standard radiation qualities (RQR) while detector was fixed in the same position and irradiated with a constant dose rate of 0.57 mGy/s *Current through the detector induced by irradiation* nt [nA] bare silicon (square) Si(square)+GOS:Tb • Current through the bare bare silicon (round) Si detector decreases ode 60 **⊢** lon. chamber with increase of X-ray L0 ද Si di photon energy 55 Scintillator enhanced Si 50 ō diodes demonstrate 45 substantial increase in the current through the 40 detector (up to 30%) 35 30

introducing scintillation light to the optical opening of the sensor and recording separately the signals directly induced in the Si bulk by X-ray photons and the ones from scintillator

First prototypes



- First prototypes of detectors have the following configurations:
- Si detectors: 300um thick, p-type bulk p-n diodes
 scintillation materials: GOS:Tb and GAGG:Ce optically coupled with Si diodes



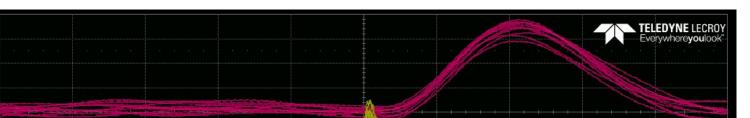
GOS: Tb scintillator optically coupled with a Si detector

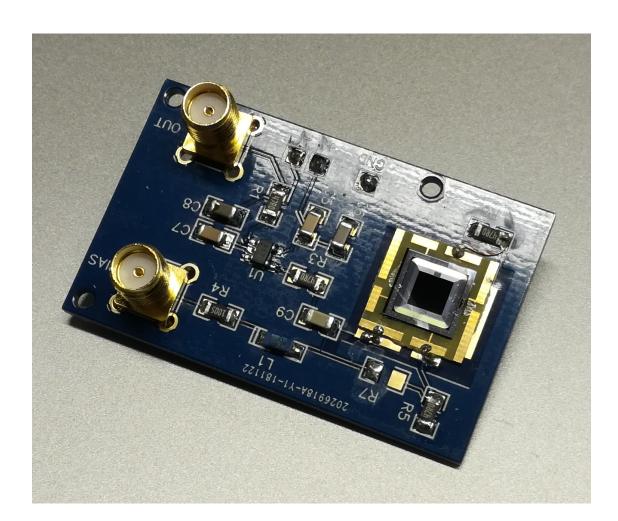
40 60 80 100 120 140 Tube voltage [kV]

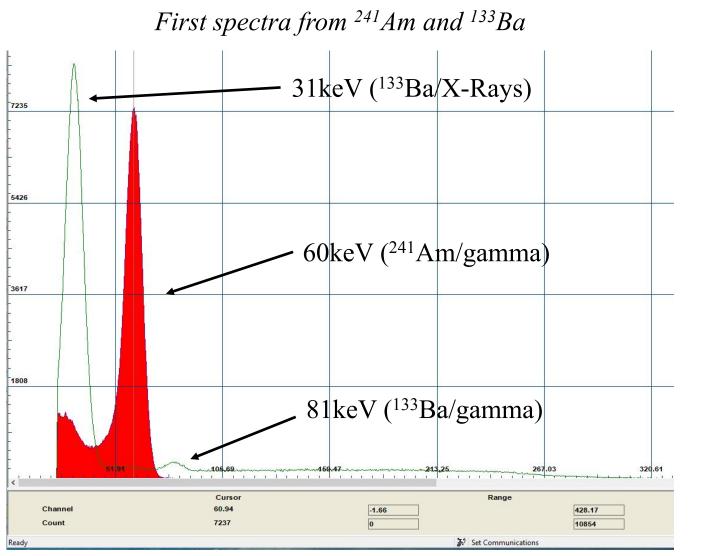
Read-out electronics

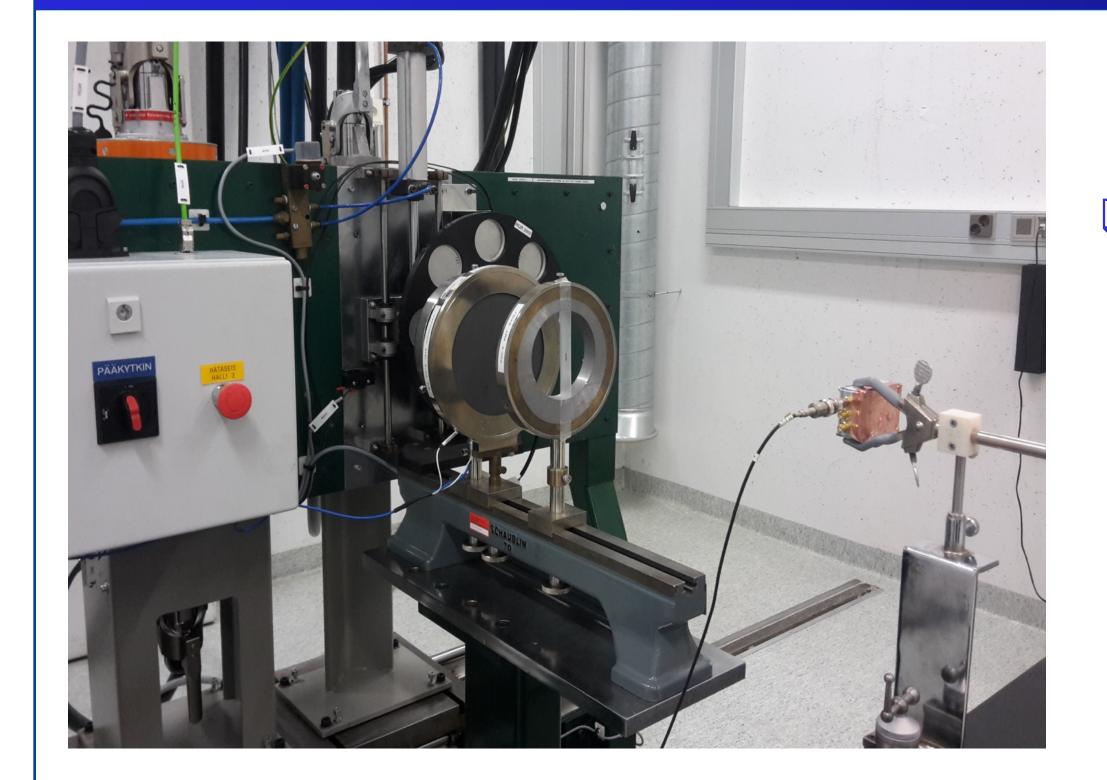
- The directly induced pulses in Si bulk and the ones caused by scintillation light are expected to differ
- Low noise preamplifier board for direct mounting of detectors has been designed in order to improve signal-to-noise ratio
- Pulse-shape discrimination analysis will be applied for separation of the pulses originated by scintillation light

Pulses from ²⁴¹Am 60keV gamma photons



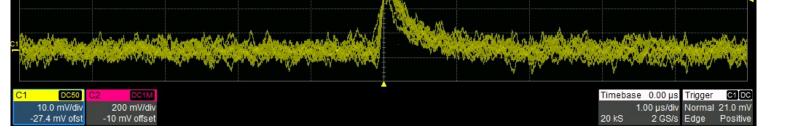






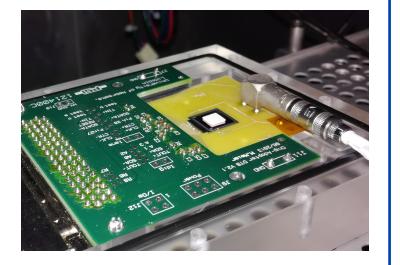
Test in STUK irradiation facility

Irradiation performed with ISOVOLT Titan E160 Series of X-ray Generator within STUK testing facility



Further developments

- Further investigation of SiS system: detailed study of signals induced in Si by scintillation light
 Optimization of SiS detectors by advanced simulation
 SiS prototyping with finely segmented pixel detectors
- Development of novel scintillation materials optimized for SiS imaging systems



Segmented pixel detector with GOS:Tb scintillator

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